	PUSAT PENGURUSAN MAKMAL UNIVERSITI (PPMU)	Form Num.	UIRL/F/132
		Version	1/2024
		Effective Date	01/03/2024
		Equipment	PECVD
		Sample Serial No.	UIRL/

MICRONANO FABRICATION & MACHINING LABORATORY

SAMPLE SUBMISSION FORM

General Rules and Requirements:

- All information provided should be true Booking will be notified/updated by email 1.
 - Booking procedure
- 2. 3.

 - a. Complete the application form including valid research vote number
 b. Submit the completed application form to UIRL Sample Acceptance Counter
 c. Fast Lane is offered to non-UTM customers with an additional 50% charge from the normal price
- Sample Condition & Preparation 4.
 - a. PPMU has the right to cancel any analysis if the sample is suspected to have a high risk on the safety of the operator or can cause damage to the instrument during the analysis. The cost of damages will be borne by the customer.

b. The remaining samples will be disposed of within a month after analysis is completed.

All enquiries regarding PECVD should be forwarded to the Science Officer (Assistant Engineer, Mr Muhammad Sulaiman Muhammad Zain, email: 5. m.sulaiman@utm.my, tel: 07-5557729) or visit our website at ppmu.utm.my.

1. APPLICANT'S PERSONAL PARTICULARS											
Name of Applicant											
Status of Applicant	Undergra	aduates		Master		PhD Researcher		her			
Student Matric No.											
Faculty/ Department											
Hand Phone No. & Email											
2. SUPERVISOR DETAILS (for internal applicant and academic institution only)											
Name of Supervisor											
Staff ID No.											
Faculty/Department											
Hand Phone No.											
Email											
Mode of Payment	Cash		EFT		Log card		Invoice	Fast I	ane		
*Deumentusing invoice	Research Vot No. (e.g.: Q.J091600.24C3.01D32)										
rayment using involce	Balance of V29000										
Signaturo & Official Stamp	*A digital signature is not recommended. Any matters raised in the future are beyond our responsibilities										
3. SAMPLE INFORMATION											
Total No. of Sample / Material											
Recipe Input	Substrate Temp. (^o C)			Wor	king Pressure (mTorr)		Pro	cess Time (sec)			
	Stabl	e Time (⁰C)			RF Power (W)		Pu	urge Time (sec)			
	Gases (sccm)										
	HiQ N ₂			Ar		N2O		NH3			
	GN2		S	F6		SiH₄		O2			
	He			- 1 - 1							
Solvent (ml)	SU-8 2002		SU Develop	-8 er	КМРБ	KMPR 1035		AZ IPS-6090 PR			
	SU-8 2010		Remover P	G	AZ 15	AZ 1505 PR		AZ nLOF 2070 Negative Resist			
	SU-8 2075		AZ 40 XT – 1	.1 D	Isopropanol			Acetone			
	AZ 826 MIF Developer		Technistr P131	р .6	Et	Ethanol					
Remarks											